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10/584,776	06/28/2006	Teruaki Yamamoto	043890-0798	4941
	7590 06/09/201 WILL & EMERY LL	EXAMINER		
600 13TH STR	*	ARCIERO, ADAM A		
WASHINGTON, DC 20005-3096			ART UNIT	PAPER NUMBER
			1727	
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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

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	Application No.	Applicant(s)	
	10/584,776	YAMAMOTO ET A	L.
Office Action Summary	Examiner	Art Unit	
	ADAM A. ARCIERO	1727	
The MAILING DATE of this communication ap Period for Reply	ppears on the cover sheet with	the correspondence add	dress
A SHORTENED STATUTORY PERIOD FOR REPLEWHICHEVER IS LONGER, FROM THE MAILING ID. - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period. Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICA .136(a). In no event, however, may a rep d will apply and will expire SIX (6) MONTH te, cause the application to become ABAN	ATION. y be timely filed IS from the mailing date of this control JOONED (35 U.S.C. § 133).	
Status			
Responsive to communication(s) filed on 18 I This action is FINAL . 2b) ☑ Thi Since this application is in condition for allowed closed in accordance with the practice under	is action is non-final. ance except for formal matter	•	merits is
Disposition of Claims			
4) ☑ Claim(s) 1-12 is/are pending in the application 4a) Of the above claim(s) 8-10 is/are withdraw 5) ☐ Claim(s) is/are allowed. 6) ☑ Claim(s) 1-7 and 11-12 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/	vn from consideration.		
Application Papers			
9) The specification is objected to by the Examin 10) The drawing(s) filed on is/are: a) ac Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the E	cepted or b) objected to by e drawing(s) be held in abeyance ction is required if the drawing(s)	e. See 37 CFR 1.85(a). is objected to. See 37 CF	` .
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreig a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority document application from the International Bureat * See the attached detailed Office action for a list	nts have been received. nts have been received in Apportity documents have been reau (PCT Rule 17.2(a)).	olication No eceived in this National S	Stage
Attachment(s)			
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)/l	nmary (PTO-413) Mail Date rmal Patent Application	

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NEGATIVE ELECTRODE MATERIAL FOR LITHIUM SECONDARY BATTERY,
NEGATIVE ELECTRODE USING THE MATERIAL, LITHIUM SECONDARY BATTERY
USING THE NEGATIVE ELECTRODE, AND MANUFACTURING METHOD OF NEGATIVE
ELECTRODE MATERIAL

Examiner: Adam Arciero S.N. 10/584,776 Art Unit 1727 May 27, 2011

Continued Examination Under 37 CFR 1.114

- 1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on February 18, 2011 has been entered. Claims 1 6 and 8 have been amended. Claims 1-12 are newly added. Claims 8-10 remain withdrawn from consideration.
- 2. The text of those sections of Title 35, U.S.C. code not included in this action can be found in a prior Office Action.

Claim Rejections - 35 USC § 103

- 3. The claim rejections under 35 U.S.C. 103(a) as being unpatentable over Shimamura et al. and Nakamoto et al. on claims 1-7 are withdrawn, because Applicant has amended the claims.
- 4. Claims 1-7 and 11-12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Shimamura et al. (WO/03/079469 using US 2005/0287439 A1 as English equivalent) in view of

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Nakamoto et al. (machine translation for JP 2000-173612) and Kawakami et al. (US 6,730,434 B1).

As to Claims 1, 3 and 6-7, Shimamura et al. discloses a negative electrode having a negative electrode material for a lithium secondary battery (claims 6-7) which is capable of storing and emitting lithium ions (pg. 3, [0038]). Said electrode material comprises a composite particle including a solid phase A which consists of silicon and a mixed phase B which consists of a transition metal element and silicon (intermetallic compound) (pg. 3, [0038]). Shimamura et al. further discloses wherein the mixed phase is microcrystalline (pg. 3, [0025]). Shimamura et al. does not specifically disclose a carbon material adhered to a part of the surface of the basic material particle and a film having a silicon oxide formed on a surface portion of the base material particle and not on the carbon.

However, Nakamoto et al. discloses that fibrous carbon is fixed over a part of the surface of a negative electrode material comprising a Si composite (paragraph [0016]). At the time of the invention, it would have been obvious to one of ordinary skill in the art to modify the electrode material of Shimamura et al. by fixing fibrous carbon (claim 3) to the composite particle, because Nakamoto et al. teaches that even if the particle is expanding and contracting with the occlusion and discharge of lithium, the contact state of each particle and the carbon conducting agent is well maintained, and charge/discharge cycle life is increased (paragraph [0016]). Nakamoto et al. and Shimamura et al. do not specifically disclose wherein the basic material particle and silicon oxide film are formed in an inert atmosphere.

However, Kawakami et al. teaches of an anode material comprising silicon which is preferably prepared and mechanically grinded in an inert atmosphere such as argon (col. 12, lines

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21-30). At the time of the invention, it would have been obvious to one of ordinary skill in the art to modify the process of Shimamura et al. by forming the basic material particle (mechanical milling/grinding) in an argon gas atmosphere, because Kawakami et al. teaches that it is important to control the oxygen content of the thin oxide coat (silicon oxide) located on the surface of the particle (col. 17, lines 44-54). Furthermore, one of ordinary skill in the art would have found it obvious to try an inert atmosphere of argon because the Board has stated that "when there is motivation to solve a problem and there are a finite number of identified, predictable solutions, a person of ordinary skill has good reason to pursue the known options within his or her technical grasp. If this leads to anticipated success, it is likely the product not of innovation but of ordinary skill and common sense." See MPEP 2141, KSR. Furthermore, it is the position of the Examiner that the properties of having a silicon oxide film formed on an exposed surface portion of the composite base material particle is inherent, given that the materials and methods for producing the negative electrode material of the prior arts and that of the present application are the same. A reference with is silent abut a claimed invention's features is inherently anticipatory if the missing feature is necessarily present in that which is described in the reference. Inherency is not established by probabilities or possibilities. *In re* Robertson, 49 USPQ2d 1949 (1999).

As to Claim 2, Nakamoto et al. teaches of using a conductive agents such as graphite and carbon fibers (pg. 5, [0061]). Nakamoto et al. is clearly teaching that graphite and carbon fibers are considered functionally equivalent for use as conductive agents in negative electrode materials. Therefore, at the time of the invention, it would have been obvious to one of ordinary

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skill in the art to substitute the graphite of Nakamoto et al. for the fibrous carbon of Shimamura et al., because Nakamoto et al. teaches that they are recognized equivalents.

As to Claim 4, Shimamura et al. and Nakamoto et al. do not specifically disclose the amount of oxygen per silicon. However, Kawakami et al. teaches of an anode material comprising silicon which is preferably prepared and mechanically grinded in an inert atmosphere such as argon (col. 12, lines 21-30). Kawakami et al. further discloses wherein the oxygen amount is preferred to be contained in an amount of 0.1% to 3% by weight (col. 17, lines 10-33). This range overlaps the claimed range. The courts have held that where the claimed ranges "overlap or lie inside ranges disclosed by the prior art" a *prima facie* case of obviousness exists. *In re Wertheim*, 541 F.2d 257, 191 USPQ 90 (CCPA 1976).

As to Claim 5, Shimamura et al. discloses wherein the amount of carbon material is 1 wt% or more and 10 wt% or less (paragraph [0018]).

As to Claims 11-12, Shimamura et al. and Nakamoto et al. do not specifically disclose wherein the inert gas is argon and where it is free of nitrogen.

However, Kawakami et al. teaches of an anode material comprising silicon which is preferably prepared and mechanically grinded in an inert atmosphere such as argon (col. 12, lines 21-30). When the inert atmosphere comprises argon, said atmosphere is free of nitrogen. At the time of the invention, it would have been obvious to one of ordinary skill in the art to modify the process of Shimamura et al. by forming the basic material particle (mechanical milling/grinding) in an argon gas atmosphere, because Kawakami et al. teaches that it is important to control the oxygen content of the thin oxide coat located on the surface of the particle (col. 17, lines 44-54). Furthermore, one of ordinary skill in the art would have found it obvious to try an inert

atmosphere of argon because the Board has stated that "when there is motivation to solve a problem and there are a finite number of identified, predictable solutions, a person of ordinary skill has good reason to pursue the known options within his or her technical grasp. If this leads to anticipated success, it is likely the product not of innovation but of ordinary skill and common sense." See MPEP 2141, KSR.

Response to Arguments

5. Applicant's arguments with respect to claims 1-7 have been considered but are moot in view of the new ground(s) of rejection as necessitated by Applicant's amendments to the claims.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to ADAM A. ARCIERO whose telephone number is (571)270-5116. The examiner can normally be reached on Monday to Friday 7am to 4pm EST.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Barbara Gilliam can be reached on 571-272-1330. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/ADAM A ARCIERO/ Examiner, Art Unit 1727

/Barbara L. Gilliam/

Supervisory Patent Examiner, Art Unit 1727